

## Trimethylsilylmethylcopper, a Stable Copper(I) Alkyl

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*Summary* Interaction of  $\text{Me}_3\text{SiCH}_2\text{Li}$  with  $\text{CuI}$  gives  $(\text{Me}_3\text{SiCH}_2\text{Cu})_n$  a stable, volatile, petroleum-soluble copper(I) alkyl (tetramer in  $\text{C}_6\text{H}_6$ , hexamer in  $n\text{-C}_6\text{H}_{14}$ ), which shows a parent ion in the mass spectrum corresponding to the tetramer ( $n = 4$ ); decomposition involves free radical pathways.

ALKYLCOPPER(I) complexes are unstable, decomposing at or below 0°,<sup>1</sup> and are soluble only in the presence of complexing agents.<sup>2</sup> Recent reports show that trimethylsilylmethyl ( $\text{Me}_3\text{SiCH}_2$ ) and related ligands form a number of kinetically-stable, binary alkyls of the early transition metals,<sup>3</sup> e.g.,  $(\text{Me}_3\text{SiCH}_2)_4\text{Ti}^4$  and  $(\text{Me}_3\text{SiCH}_2)_4\text{Cr}$ ;<sup>5</sup> we now describe the preparation of trimethylsilylmethylcopper, a volatile alkylcopper(I) compound, stable at room temperature and readily soluble in non-polar media.

Treatment of copper(I) iodide in n-hexane-ether (1:1) with lithiomethyltrimethylsilane at ca.  $-10^\circ$  gave  $(\text{Me}_3\text{SiCH}_2\text{Cu})_n$  as colourless prisms, m.p.  $78-79^\circ$  (dec.), from n-pentane. The crystals, or a solution in hydrocarbon solvent, are stable in the dark at room temperature, but decomposition occurs upon exposure to light. Cryoscopy of 10% w/w solutions showed that it is tetrameric in benzene and hexameric in cyclohexane. (The structure may resemble that of alkyl-lithium reagents.) The  $^1\text{H}$  n.m.r. spectrum indicated that it is diamagnetic, the  $\text{Me}_3\text{Si}$  and  $\text{CH}_2$  resonances appearing as singlets at  $\tau$  9.80 and 10.18 respectively. The mass spectrum showed a parent ion for the tetramer at  $m/e$  600 for  $(\text{Me}_3\text{SiCH}_2^{63}\text{Cu})_4^+$  with the expected  $\text{Cu}_4$  isotope pattern. Fragmentation occurs with loss of Me,  $\text{Me}_4\text{Si}$ ,  $\text{Me}_4\text{Si} + \text{CH}_4$ ,  $(\text{Me}_3\text{Si})_2\text{CH}_2$ , and  $2\text{Me}_4\text{Si}$ . Pyrolysis *in vacuo* gave a copper mirror and a volatile,

colourless liquid containing  $\text{Me}_4\text{Si}$  (major product),  $(\text{Me}_3\text{Si})_2\text{CH}_2$ ,  $(\text{Me}_3\text{SiCH}_2)_2$ , and three unidentified minor components. Photolysis or pyrolysis (at  $80^\circ$ ) in toluene gave an unidentified, intensely red, copper-containing species,  $\text{Me}_4\text{Si}$ ,  $(\text{Me}_3\text{Si})_2\text{CH}_2$  (only on pyrolysis),  $(\text{Me}_3\text{SiCH}_2)_2$ ,  $\text{PhCH}_2\text{CH}_2\text{SiMe}_3$ , and  $(\text{PhCH}_2)_2$ , in accord with a free radical decomposition pathway.

The stability of  $(\text{Me}_3\text{SiCH}_2\text{Cu})_n$  is presumably associated with the preclusion of the olefin-elimination route to decomposition and the presence of a stable metal cluster (X-ray studies are in hand).

$(\text{Me}_3\text{SiCH}_2\text{Cu})_n$  is an alkylating agent: reaction with  $\text{Me}_3\text{SiCl}$ ,  $\text{CH}_2=\text{CHCH}_2\text{Br}$ , or  $\text{PhI}$  gave  $(\text{Me}_3\text{Si})_2\text{CH}_2$ ,  $\text{Me}_3\text{SiCH}_2\text{CH}_2\text{CH}=\text{CH}_2$ , or  $\text{PhCH}_2\text{SiMe}_3$ , respectively; with  $\text{PhCH}_2\text{Br}$ ,  $(\text{PhCH}_2)_2$  (presumably *via* halogen-metal exchange), as well as the expected  $\text{PhCH}_2\text{CH}_2\text{SiMe}_3$  was formed. The copper-lithium reagent,  $[(\text{Me}_3\text{SiCH}_2)_2\text{CuLi}]$ , was obtained as a pale-violet, ethereal solution from  $\text{CuI}$  (1 mol) and  $\text{Me}_3\text{SiCH}_2\text{Li}$  (2 mol) and was unchanged after several days at room temperature.

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